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## New Technologies and Processing of Photoelectric Functional Materials and Devices

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### Message from the Guest Editors

This Special Issue on “New Technologies and Processing of Photoelectric Functional Materials and Devices” seeks high-quality works focusing on the latest functional materials for photoelectrical devices. Topics include, but are not limited to:

- Perovskite materials;
- Low-dimensional materials and heterostructures;
- Organic materials;
- Quantum dots;
- Light-emitting diodes (LEDs);
- Photodetectors;
- Photovoltaic devices.

Deadline for manuscript submissions:

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# Special Issue



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## Message from the Editor-in-Chief

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